NANOSECOND LASERS

NL200 • NL230 • NL300

NL200 SERIES



BENEFITS

- ► Continuous tuning of repetition rate while maintaining constant pulse energy, superior beam pointing and energy stability make the laser the first choice for micromachining, marking, thin film removing applications
- Close to Gaussian smooth beam profile with low value $M^2 < 1.3$ and good focusability is beneficial for such applications, as LCD and OLED display repair
- Compactness and lightness make a laser easy transportable, saves on valuable laboratory space

NL200 series DPSS air-cooled nanosecond lasers offer high pulse energy at kHz repetition rates. End-pumped design makes this laser compact and easy to integrate into various laser equipment both industrial and R&D. Featuring short nanosecond pulse duration, variable repetition rate and external TTL triggering, nanosecond diode pumped NL200 series Q-switched lasers are excellent and cost-effective sources for specific applications, when higher pulse energy is required, like material processing, LCD and OLED

- Fast wavelength selection is superior for applications where alternating wavelengths are required, like material ablation, LIBS
- ▶ Air cooling, cheap and reliable end-pumping technology, amplifiers free DPSS design guarantee easy operation and alignment of laser, simple installation and low life-time ownership cost
- Variety of control interfaces USB, RS232, LAN, WLAN ensure easy control and integration of laser with laboratory or OEM equipment

display panel repair, ablation, marking, engraving, laser cleaning, laser deposition and many more.

This laser can be equipped with harmonic generation modules for 532 nm, 355 nm, 266 nm and 213 nm wavelengths. Excellent energy stability and a wide range of wavelength options make this laser a perfect tool for spectroscopy, photoacoustic imaging and remote sensing applications. The mechanically stable and hermetically sealed design ensures reliable operation and long lifetime of the laser components.

Compact **O**-switched **DPSS** Lasers

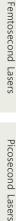
FEATURES

- Up to 4 mJ pulse energy at 1064 nm
- ▶ Up to 2500 Hz variable repetition rate
- ▶ 532 nm, 355 nm, 266 nm wavelengths as standard options
- <10 ns pulse duration at 1064 nm</p>
- Electro-optical Q-switching
- Turn-key operation
- Rugged sealed cavity
- Compact size
- Simple and robust
- Air cooled
- External TTL triggering
- Remote control via keypad and/or any controller running on any OS using REST API commands

APPLICATIONS

- Material processing
- ▶ LCD and OLED display panel repair
- Marking
- Micromachining
- Engraving
- Laser deposition
- Laser cleaning
- Ablation
- Spectroscopy
- OPO pumping
- Remote sensing

Because of its robust design and diode-pumped technology this laser can work 24/7 with minimal down time and low ownership cost.



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Other Ekspla Products



NL200 SERIES

SPECIFICATIONS ¹⁾

NL201 ³⁾	NL202 4)	NL204 ⁴⁾
0.9 mJ	2.0 mJ	4.0 mJ
0.3 mJ	0.9 mJ	2.0 mJ
0.2 mJ	0.6 mJ	1.3 mJ
0.08 mJ	0.2 mJ	0.6 mJ
	inquire	
	<0.5 %	
<2.5 %		
<3.5 %		
<4.0 %		
inquire		
7 – 10 ns		
	± 2 %	
0-2500 Hz	0-10	00 Hz
close to Gaussian in near and far fields		
0.9–1.1 at 1064 nm		
<1.3		
<3 mrad		
linear		
0.7 mm		
≤10 µrad		
<0.5 ns		
	464 222 22	
470 × 390 × 140 mm		
	3 m	
	air cooled	
18–30 °C		
	20-80 % (non-condensing)	
100		0 Hz
	<600 W	
	not worse than ISO Class 9	
 time interval. FWHM at 1064 nm. FWHM at 1064 nm. Measured over 8 hours period a warm-up when ambient temperais less than ± 2 °C and humidity Full angle measured at the 1/e² l 1064 nm. Beam diameter is measured at 10 1/e² level. Beam pointing stability is evaluai 	fter 20 min ature variation <± 5%. evel at 064 nm at the ted as	VISILE AND/OR INVISILE LASER RADIATA ANDID FY OR SAIN EXOLUTE TO AND ANDID FY OR SAIN EXOLUTE TO ANDALON MEMORY AND AND AND AND AND AND AND AND MEMORY AND AND AND AND AND AND AND AND AND AND AND AND AND AND AND AND AND AND AND
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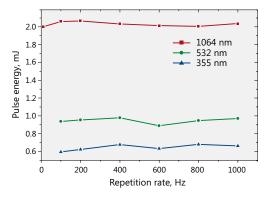
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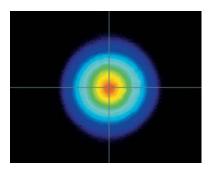


NL200 SERIES

PERFORMANCE

OUTLINE DRAWINGS





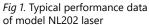


Fig 2. Typical beam intensity profile in the far field

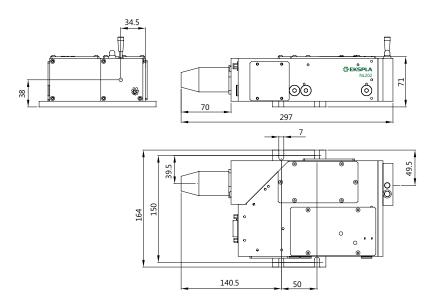


Fig 3. NL202 laser head drawing

ORDERING INFORMATION

Note: Laser must be connected to the mains electricity all the time. If there will be no mains electricity for longer that 1 hour then laser (system) needs warm up for a few hours before switching on.

NL201-H200SHC

Model	Harmonic generator options:
	H200SHC \rightarrow second harmonic
	H200THC \rightarrow third harmonic
	H200FHC \rightarrow fourth harmonic

Picosecond Lasers

